

Supporting Information

Multiple Stimuli Dual-Optical Mode Responsive Hybrid Copper (I) Halides for Advanced Anti-counterfeiting and Information Encryption

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Table S1. Crystal data and structure refinement for $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

Compound	$(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$	$(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$
Empirical formula	$\text{C}_{38}\text{H}_{36}\text{P}_2\text{Cu}_2\text{I}_4 \cdot \text{C}_3\text{H}_7\text{NO}$	$\text{C}_{38}\text{H}_{36}\text{P}_2\text{Cu}_4\text{I}_6$
Formula weight	1262.38	1570.17
Temperature /K	296	296
Crystal system	monoclinic	trigonal
Space group (number)	$C2/c$	$R\bar{3}c$
a /Å	24.6028(9)	13.9610(11)
b /Å	10.7595(4)	13.9610(11)
c /Å	18.9219(6)	40.083(5)
α /°	90	90
β /°	116.4580(10)	90
γ /°	90	120
Volume/ Å ³	4484.3(3)	6765.9(13)
Z	4	6
ρ_{calc} /g·cm ⁻³	1.87	2.312
μ /mm ⁻¹	3.804	6.064
$F(000)$	2416	4368.0
Radiation	MoK_α ($\lambda = 0.71073$ Å)	
2θ range /°	4.214 - 58.442	5.28 - 52.752
	$-33 \leq h \leq 33$	$-17 \leq h \leq 17$
Index ranges	$-14 \leq k \leq 14$	$-17 \leq k \leq 17$
	$-25 \leq l \leq 25$	$-50 \leq l \leq 49$
Reflections collected	36008	28262
Independent reflections	6070 [$R_{\text{int}} = 0.0343$, $R_{\text{sigma}} = 0.0276$]	1545 [$R_{\text{int}} = 0.0483$, $R_{\text{sigma}} = 0.0194$]
Data / Restraints / Parameters	6070/57/256	1545/0/83

Table S1. Crystal data and structure refinement for $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

Compound	$(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$	$(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$
Goodness-of-fit on F^2	1.025	1.076
Final R indexes [$I \geq 2\sigma(I)$]	$R_1 = 0.0426$, $wR_2 = 0.0881$	$R_1 = 0.0276$, $wR_2 = 0.0552$
Final R indexes [all data]	$R_1 = 0.0745$, $wR_2 = 0.1004$	$R_1 = 0.0437$, $wR_2 = 0.0607$
Largest peak/hole /eÅ ⁻³	1.14/-1.46	0.67/-0.70

$R_1 = \sum ||F_o - F_c|| / \sum |F_o|$, $wR_2 = \{\sum [w(|F_o|^2 - |F_c|^2)^2] / \sum [w(|F_o|^4)]^{1/2}$ and $w = 1/[\sigma^2(F_o^2) + (0.0462P)^2]$ where $P = (F_o^2 + 2F_c^2)/3$

Table S2. Fractional atomic coordinates and equivalent isotropic displacement parameters (\AA^2) for $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$. U_{eq} is defined as 1/3 of the trace of the orthogonalised U_{ij} tensor.

Atom	<i>x</i>	<i>y</i>	<i>z</i>	U_{eq}
($\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$				
I (1)	5098.1(2)	1719.2(3)	646.0(2)	57.30(11)
I (2)	6668.3(2)	89.2(4)	316.3(3)	84.06(15)
Cu (1)	5603.1(3)	105.1(6)	135.4(3)	59.17(16)
P (1)	6043.2(4)	5436.7(9)	1595.9(5)	35.6(2)
C (7)	6354.3(17)	5233(4)	908(2)	37.9(8)
C (6)	6364.7(18)	6801(3)	2180(2)	39.1(8)
C (13)	6209.7(18)	4127(3)	2241(2)	38.9(8)
C (19)	5237.7(18)	5599(4)	1052(2)	47.1(9)
C (8)	6306.7(19)	4096(4)	540(2)	46.9(9)
C (12)	6609(2)	6247(4)	706(3)	50.7(10)
C (1)	6845.3(19)	6671(4)	2927(2)	48.0(10)
C (5)	6154(2)	7976(4)	1892(3)	53.5(11)
C (2)	7099(2)	7707(5)	3380(3)	60.6(12)
C (18)	6708(2)	3381(4)	2417(3)	57.9(11)
C (9)	6514(2)	3970(5)	-26(3)	56.0(11)
C (14)	5841(2)	3896(4)	2602(3)	55.1(11)
C (3)	6892(2)	8866(4)	3090(3)	60.5(12)
C (10)	6772(2)	4973(5)	-215(3)	64.6(13)
C (4)	6427(2)	9003(4)	2349(3)	62.7(12)
C (15)	5971(3)	2919(5)	3129(3)	69.2(14)
C (11)	6817(2)	6097(5)	144(3)	65.5(13)
C (16)	6465(3)	2192(5)	3295(3)	71.8(15)
C (17)	6831(3)	2411(5)	2942(3)	74.7(15)

Table S2. Fractional atomic coordinates and equivalent isotropic displacement parameters (\AA^2) for $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$. U_{eq} is defined as 1/3 of the trace of the orthogonalised U_{ij} tensor.

Atom	<i>x</i>	<i>y</i>	<i>z</i>	U_{eq}
C (22)	5294(5)	7661(9)	2888(6)	62(2)
O (1)	5169(5)	6580(6)	2688(5)	75(3)
N (1)	5031(9)	8639(6)	2429(8)	50(3)
C (21)	5202(6)	9902(8)	2717(8)	81(4)
C (20)	4540(5)	8470(12)	1643(6)	78(3)
$(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$				
I (1)	10568.4(3)	2028.6(2)	5466.8(2)	54.98(12)
P (1)	6666.67	3333.33	5057.4(4)	38.0(4)
Cu (1)	9094.8(8)	375.2(9)	5147.6(2)	48.7(3)
Cu (2)	10000	0	5409.6(4)	47.6(4)
C (2)	6249(3)	1972(3)	5207.4(9)	41.4(9)
C (7)	6666.67	3333.33	4611.2(16)	64(2)
C (3)	5430(4)	1467(4)	5437.6(12)	63.9(13)
C (1)	6801(5)	1440(4)	5100.9(13)	72.9(15)
C (5)	5738(5)	-52(4)	5466.8(13)	75.1(15)
C (4)	5177(5)	445(4)	5567.2(13)	82.0(16)
C (6)	6541(5)	421(4)	5231.7(15)	86.0(17)

Table S3. Important bond lengths for $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

Atom	Atom	Length/ \AA	Atom	Atom	Length/ \AA
$(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$					
Cu (1)	I (1)	2.5619(7)	P (1)	C (7)	1.794(4)
Cu (1)	I (2)	2.4871(7)	P (1)	C (6)	1.795(4)
Cu (1 ¹)	I (1)	2.5965(7)	P (1)	C (13)	1.788(4)
Cu (1)	Cu (1) ¹	2.7865(12)	P (1)	C (19)	1.789(4)
$(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$					
I (1)	Cu (1)	2.5395(11)	Cu (1)	Cu (1) ⁴	1.9834(14)
I (1)	Cu (1) ²	2.6359(10)	Cu (1)	Cu (1) ⁵	2.7568(17)
I (1)	Cu (1) ³	2.5775(11)	Cu (1)	Cu (2)	1.9070(13)
I (1)	Cu (2)	2.5408(4)	Cu (1)	Cu (2) ⁶	2.7427(16)
Cu (1)	Cu (1) ²	1.9834(14)	Cu (1)	Cu (1) ³	2.7568(17)

Symmetry code 1: 1- x , - y , - z ; 2: 1+ y , 1- x + y , 1- z ; 3: 2+ y - x , 1- x , + z ; 4: - y + x , -1+ x , 1- z ; 5: 1- y , -1+ x - y , + z ; 6: 2- x , - y , 1- z .

Table S4. Important bond angles for $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

Atom	Atom	Atom	Angle/ $^\circ$	Atom	Atom	Atom	Angle/ $^\circ$
$(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$							
Cu (1)	I (1)	Cu (1) ¹	65.39(2)	I (2)	Cu (1)	I (1)	117.72(3)
I (1)	Cu (1)	I (1) ¹	114.61(2)	I (2)	Cu (1)	I (1)	127.66(3)
I (1) ¹	Cu (1)	Cu (1) ¹	56.70(2)	I (2)	Cu (1)	Cu (1) ¹	174.40(4)
I (1)	Cu (1)	Cu (1) ¹	57.91(2)				
$(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$							
Cu (1)	I (1)	Cu (1) ²	65.19(4)	Cu (2)	Cu (1)	Cu (1) ⁷	89.64(4)
Cu (1) ²	I (1)	Cu (1) ³	44.70(3)	Cu (2)	Cu (1)	Cu (2) ⁸	87.95(7)
Cu (1)	I (1)	Cu (1) ³	45.02(3)	I (1) ⁶	Cu (2)	I (1)	119.196(11)
Cu (1)	I (1)	Cu (2)	44.09(3)	I (1) ⁶	Cu (2)	I (1) ¹	119.197(11)
Cu (2)	I (1)	Cu (1) ²	43.74(3)	I (1) ²	Cu (2)	I (1)	119.196(11)
Cu (2)	I (1)	Cu (1) ³	63.96(4)	I (1) ²	Cu (2)	Cu (1) ⁸	59.70(3)
I (1)	Cu (1)	I (1) ⁶	117.86(4)	I (1)	Cu (2)	Cu (1) ⁷	110.82(4)
I (1)	Cu (1)	I (1) ⁷	121.59(4)	I (1) ⁶	Cu (2)	Cu (1) ³	111.68(4)
I (1) ⁶	Cu (1)	I (1) ⁷	120.11(4)	I (1)	Cu (2)	Cu (1) ³	59.71(3)
I (1) ⁶	Cu (1)	Cu (1) ²	107.97(3)	I (1) ²	Cu (2)	Cu (1) ³	110.81(4)
I (1)	Cu (1)	Cu (1) ²	58.07(4)	I (1) ²	Cu (2)	Cu (1) ⁷	111.68(4)
I (1) ⁷	Cu (1)	Cu (1) ⁶	107.56(3)	I (1) ⁶	Cu (2)	Cu (1) ⁷	59.70(3)
I (1) ⁶	Cu (1)	Cu (1) ⁶	56.73(4)	I (1)	Cu (2)	Cu (1) ⁸	111.68(4)
I (1)	Cu (1)	Cu (1) ⁶	109.09(3)	I (1) ⁶	Cu (2)	Cu (1) ⁸	110.82(4)
I (1) ⁷	Cu (1)	Cu (1) ²	108.37(3)	Cu (1)	Cu (2)	I (1)	67.91(3)
I (1) ⁷	Cu (1)	Cu (2) ⁸	56.34(3)	Cu (1) ²	Cu (2)	I (1)	69.15(3)
I (1) ⁶	Cu (1)	Cu (2) ⁸	108.89(4)	Cu (1)	Cu (2)	I (1) ²	151.74(8)
I (1)	Cu (1)	Cu (2) ⁸	110.04(4)	Cu (1)	Cu (2)	I (1) ⁶	69.15(3)
Cu (1) ³	Cu (1)	I (1)	70.06(4)	Cu (1) ⁶	Cu (2)	I (1) ⁶	67.91(3)
Cu (1) ³	Cu (1)	I (1) ⁶	146.73(4)	Cu (1) ²	Cu (2)	I (1) ²	67.91(3)

Table S4. Important bond angles for $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

Atom	Atom	Atom	Angle/ $^\circ$	Atom	Atom	Atom	Angle/ $^\circ$
Cu (1) ⁷	Cu (1)	I (1) ⁷	64.92(5)	Cu (1) ²	Cu (2)	I (1) ⁶	151.75(8)
Cu (1) ⁷	Cu (1)	I (1)	148.07(4)	Cu (1) ⁶	Cu (2)	I (1)	151.75(8)
Cu (1) ⁷	Cu (1)	I (1) ⁶	69.20(4)	Cu (1) ⁶	Cu (2)	I (1) ²	69.15(3)
Cu (1) ³	Cu (1)	I (1) ⁷	66.10(5)	Cu (1) ⁶	Cu (2)	Cu (1) ²	92.58(7)
Cu (1) ³	Cu (1)	Cu (1) ⁶	90.000(1)	Cu (1) ⁶	Cu (2)	Cu (1) ³	92.06(7)
Cu (1) ³	Cu (1)	Cu (1) ²	45.97(3)	Cu (1) ⁶	Cu (2)	Cu (1) ⁸	46.31(3)
Cu (1) ⁶	Cu (1)	Cu (1) ²	60	Cu (1) ⁷	Cu (2)	Cu (1) ⁸	60.34(5)
Cu (1) ³	Cu (1)	Cu (1) ⁷	88.05(7)	Cu (1)	Cu (2)	Cu (1) ⁷	46.31(3)
Cu (1) ⁷	Cu (1)	Cu (1) ²	90	Cu (1)	Cu (2)	Cu (1) ³	46.31(3)
Cu (1) ⁷	Cu (1)	Cu (1) ⁶	45.97(3)	Cu (1) ³	Cu (2)	Cu (1) ⁸	60.34(5)
Cu (1) ⁷	Cu (1)	Cu (2) ⁸	44.05(3)	Cu (1) ⁶	Cu (2)	Cu (1)	92.58(7)
Cu (1) ³	Cu (1)	Cu (2) ⁸	44.05(3)	Cu (1) ²	Cu (2)	Cu (1) ³	46.31(3)
Cu (2)	Cu (1)	I (1) ⁶	67.10(3)	Cu (1) ²	Cu (2)	Cu (1)	92.58(7)
Cu (2)	Cu (1)	I (1)	67.99(3)	Cu (1) ⁶	Cu (2)	Cu (1) ⁷	46.31(3)
Cu (2)	Cu (1)	I (1) ⁷	144.27(6)	Cu (1) ²	Cu (2)	Cu (1) ⁷	92.06(7)
Cu (2) ⁸	Cu (1)	Cu (1) ²	59.83(2)	Cu (1)	Cu (2)	Cu (1) ⁸	92.06(7)
Cu (2)	Cu (1)	Cu (1) ⁶	43.71(3)	Cu (1) ³	Cu (2)	Cu (1) ⁷	60.34(5)
Cu (2)	Cu (1)	Cu (1) ²	43.71(3)	Cu (1) ²	Cu (2)	Cu (1) ⁸	46.32(3)
Cu (2) ⁸	Cu (1)	Cu (1) ⁶	59.83(2)	Cu (2)	Cu (1)	Cu (1) ³	89.64(4)

Symmetry code 1: 1- x , - y , - z ; 2: 2+ y - x , 1- x , + z ; 3: 1+ y , 1- x + y , 1- z ; 4: 1+ y - x , 1- x , + z ; 5: 1- y , + x - y , + z ; 6: 1- y , -1+ x - y , + z ; 7: - y + x , -1+ x , 1- z ; 8: 2- x , - y , 1- z .

Table S5. Comparison of PL parameters for $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$, $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$ and other copper halides.

Compound	PL/nm	PLQY/%	σ^2	Δd	Ref
$(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$	480	3.78	46.54	2.11×10^{-4}	This work
$(\text{Bmpip})_2\text{Cu}_2\text{Br}_4$	620	48.2	36.73	5.61×10^{-4}	[1]
$(\text{TEP})_2\text{Cu}_2\text{Br}_4$	503	92	119.98	1.12×10^{-3}	[2]
$[\text{N}(\text{C}_2\text{H}_5)_4]_2\text{Cu}_2\text{Br}_4$	463	97.08	141.75	6.5×10^{-4}	[3]
$(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$	536	77.56	3.557	2.35×10^{-4}	This work
			0.972	0	
$(\text{TPP})_2\text{Cu}_4\text{I}_6 \cdot 2\text{DMSO}$	515	99.5	19.13	7.01×10^{-6}	[4]
			3.38	1.94×10^{-5}	
$[\text{N}(\text{C}_3\text{H}_7)_4]_2[\text{Cu}_4\text{Br}_6]$	664	97	5.16	2.25×10^{-5}	[5]
			4.15	8.88×10^{-6}	
			3.80	4.3×10^{-6}	
			1.30	1.34×10^{-5}	
$(\text{C}_{20}\text{H}_{20}\text{P})_2\text{Cu}_4\text{Br}_6$	580	76.59	6.61	1.88×10^{-4}	[6]
			4.02	1.47×10^{-3}	
			12.27	7.25×10^{-5}	
			19.71	7.97×10^{-4}	

Table S6. The stimulus, response mode and trigger condition of hybrid metal halides in anti-counterfeiting applications.

Compounds	Stimulus	Response mode	Trigger Condition	Ref.
(MePPh ₃) ₂ Cu ₂ I ₄ ·DMF	Solvent-induced	Dual response (UV+PL)	Naked eye /UV light	This work
(TEP) ₂ Cu ₂ Br ₄	Solvent-induced	Mono response (PL)	UV light	[2]
(TEP) ₂ Cu ₄ Br ₆	Solvent-induced	Mono response (PL)	UV light	[2]
[ETPP] ₂ Cu ₄ Br ₆	Thermo-induced	Triple response (PL+RL+SHG)	UV/Blue light	[7]
[ETPP]CuBr ₂	Solvent-induced	Triple response (PL+RL+SHG)	UV/Blue light	[7]
(TPA)CuBr ₂	Solvent-induced	Mono response (PL)	UV light	[8]
(TPA) ₂ Cu ₄ Br ₆	Thermo-induced	Mono response (PL)	UV light	[8]
[Ph ₃ EtP] ₂ Sb ₂ Cl ₈	Solvent-induced	Mono response (PL)	UV light	[9]
[Ph ₃ EtP] ₂ SbCl ₅ ·EtOH	Thermo-induced	Mono response (PL)	UV light	[9]
[Ph ₃ EtP] ₂ SbCl ₅	Solvent-induced	Mono response (PL)	UV light	[9]
(PPZ) ₂ SbCl ₇ ·5H ₂ O	Solvent-induced	Mono response (PL)	UV light	[10]
[Bzmim] ₃ SbCl ₆	Thermo-induced	Mono response (PL)	UV light	[11]
[Bzmim] ₂ SbCl ₅	Solvent-induced	Mono response (PL)	UV light	[11]
(C ₉ H ₁₅ N ₃)SbCl ₅	Solvent-induced	Mono response (PL)	UV light	[4]
α -[DHEP]SbCl ₅	Solvent-induced	Mono response (PL)	UV light	[12]
β -[DHEP]SbCl ₅ ·2H ₂ O	Solvent/Thermo-induced	Mono response (PL)	UV light	[12]
β -[DHEP]SbCl ₅	Solvent-induced	Mono response (PL)	UV light	[12]
[DPA] ₃ SbCl ₆	Solvent-induced	Mono response (PL)	UV light	[13]
β -[Bmmim] ₂ SbCl ₅	Crystalline-Phase-Recognition-Induced	Mono response (PL)	UV light	[14]

Table S6. The stimulus, response mode and trigger condition of hybrid metal halides in anti-counterfeiting applications.

Compounds	Stimulus	Response mode	Trigger Condition	Ref.
(C ₆ N ₂ H ₁₆)MnBr ₄	Solvent-induced	Mono response (PL)	UV light	[15]
C ₆ N ₂ H ₁₆ MnBr ₄ (H ₂ O) ₂	Solvent-induced	Mono response (PL)	UV light	[15]
(EtTPP) ₂ MnBr ₄	Solvent-induced	Mono response (PL)	UV light	[16]
(R/S)-(C ₁₂ H ₁₆ N ₂)ZnBr ₄	Thermo-induced	Dual response (PL+CD)	UV light/CPL detector	[16]
(R/S)-(C ₁₂ H ₁₅ N ₂) ₂ ZnBr ₄	Solvent-induced	Dual response (PL+CD)	UV light/CPL detector	[17]

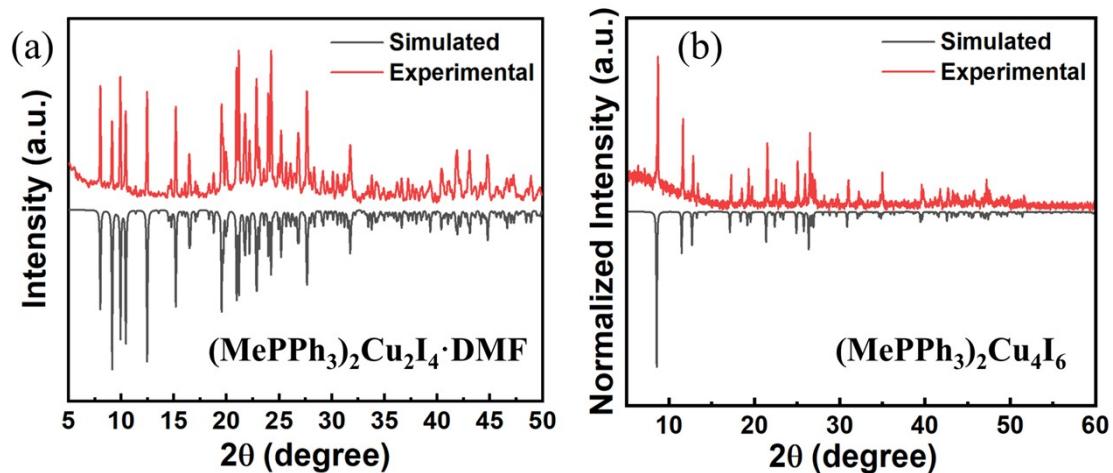


Figure S1. The simulated and experimental powder XRD patterns of (a) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (b) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

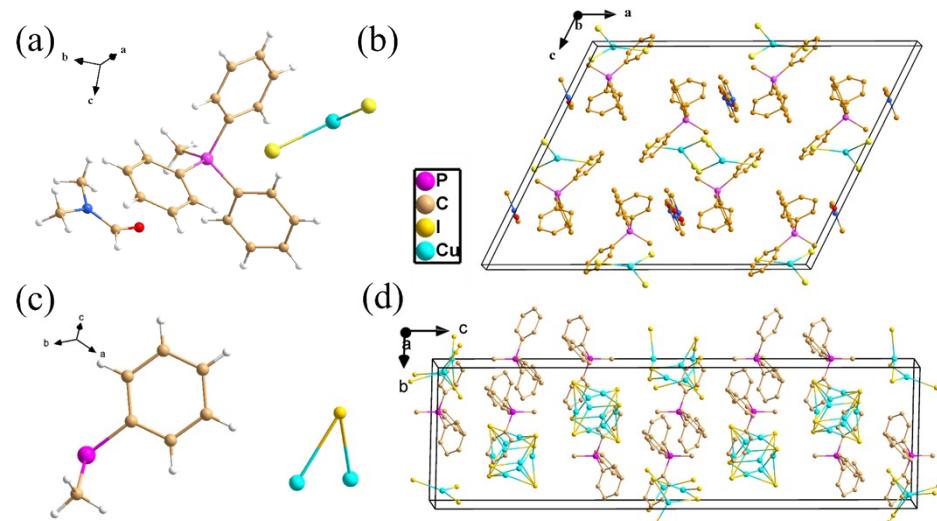


Figure S2. Asymmetric units and unit cell diagram of (a, b) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (c, d) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

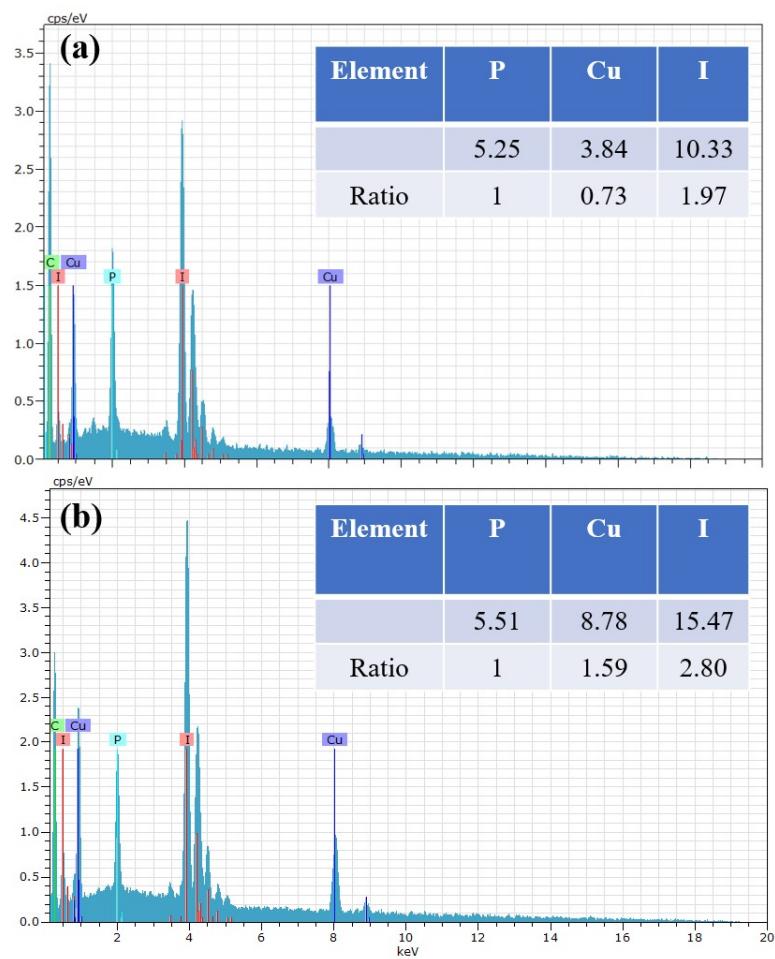


Figure S3. The EDS analysis for (a) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (b) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

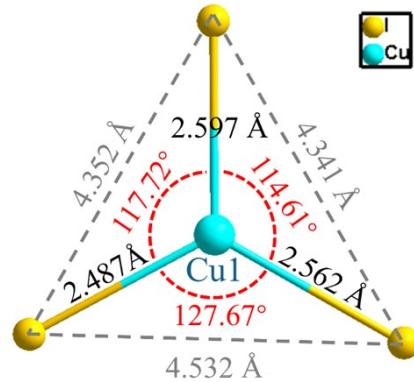


Figure S4. The bond lengths and bond angles of $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$.

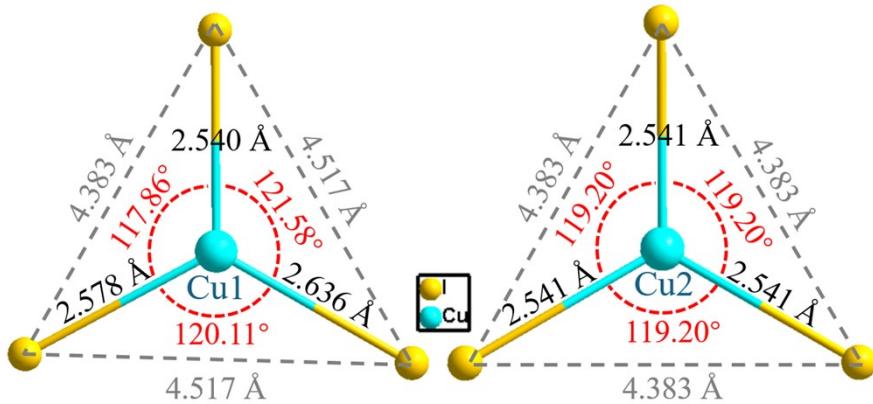


Figure S5. The bond lengths and bond angles of $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

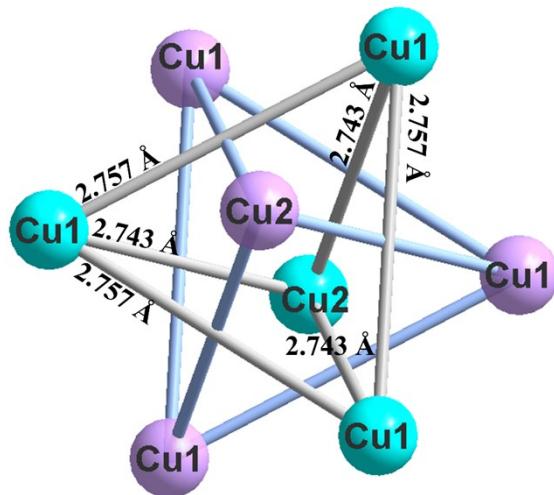


Figure S6. A detailed view of the distorted Cu cluster skeleton in $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

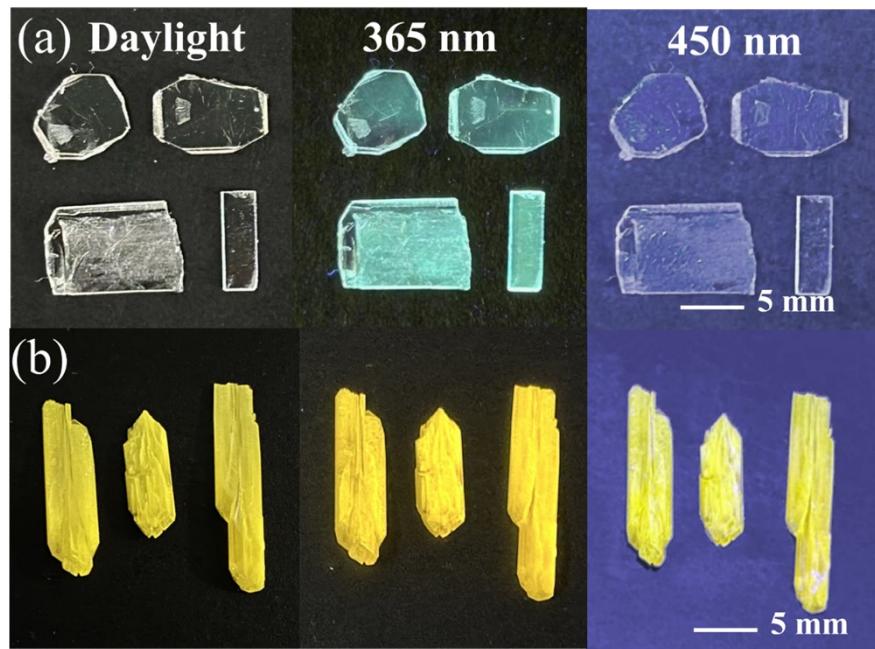


Figure S7. The optical photographs of (a) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (b) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

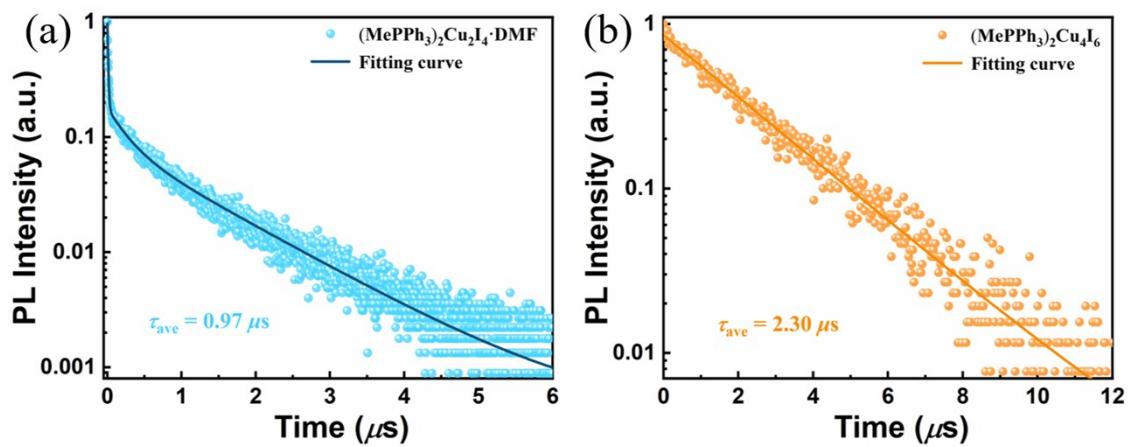


Figure S8. The PL decay lifetime of for (a) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (b) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

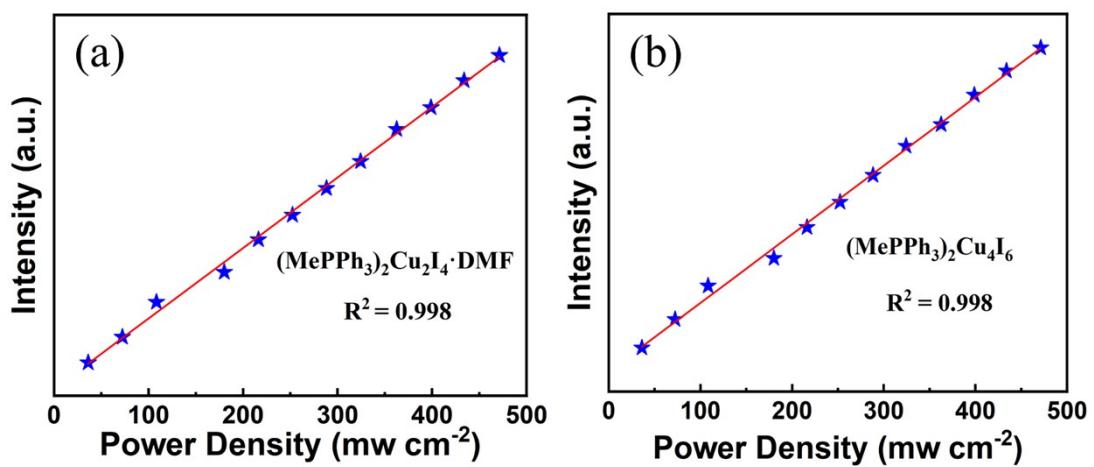


Figure S9. Power density dependent PL intensity of (a) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (b) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

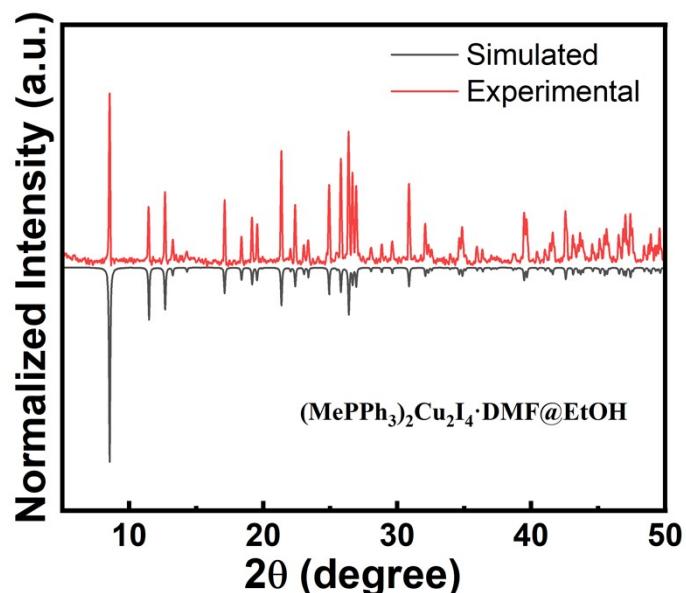


Figure S10. The simulated and experimental powder XRD patterns of (a) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ under ethanol stimulus.

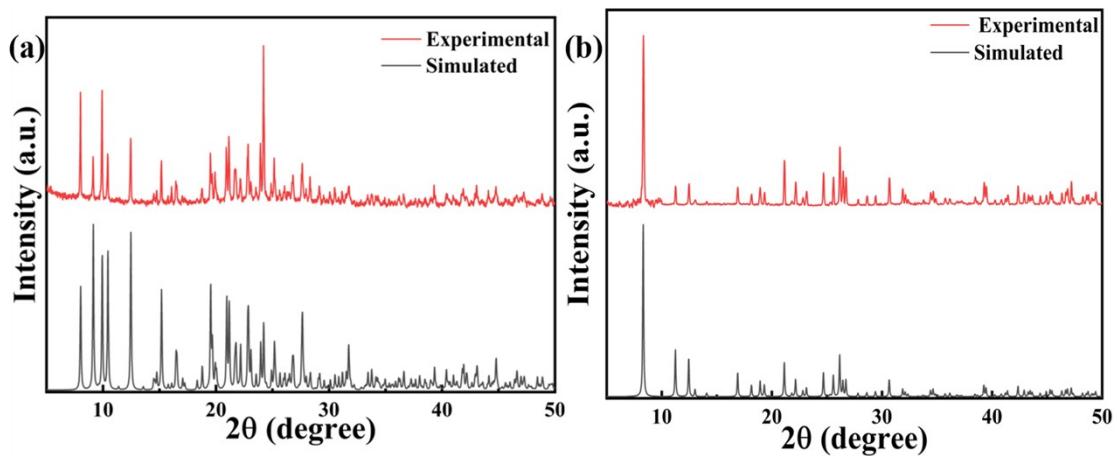


Figure S11 The Powder XRD patterns of (a) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (b) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$ after storage in the ambient air for ten days.

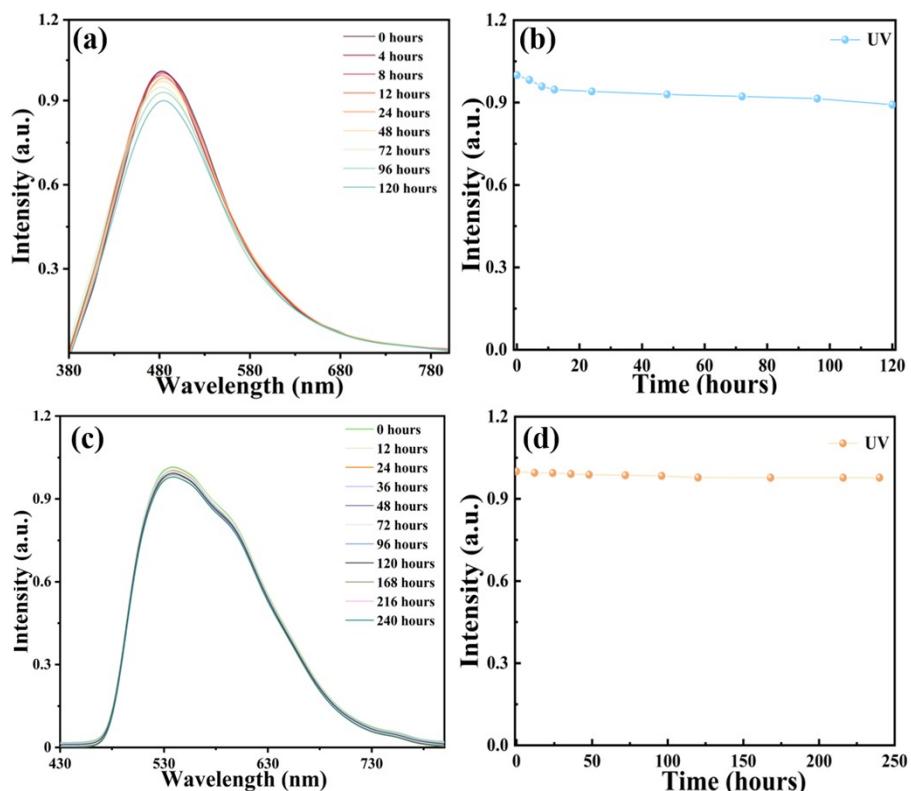


Figure S12. The time-dependent PL intensity spectra of (a, b) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (c, d) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$ with time under the continuous irradiation with 40 W UV light.

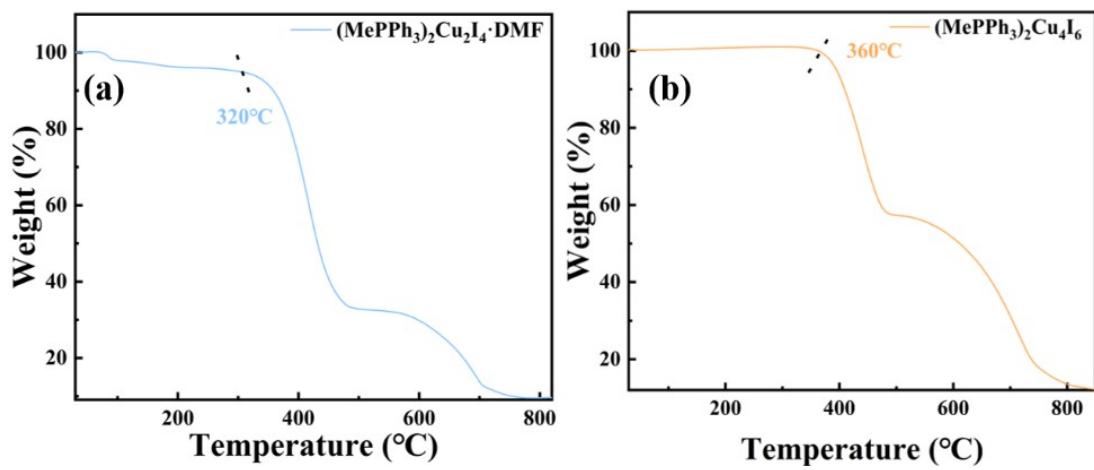


Figure S13. The TGA curves of (a) $(\text{MePPh}_3)_2\text{Cu}_2\text{I}_4 \cdot \text{DMF}$ and (b) $(\text{MePPh}_3)_2\text{Cu}_4\text{I}_6$.

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